

# Laser SEE Testing of Commercial SRAMs and Correlation with Heavy Ion Data

Mario Sacristan Barbero, Vincent Pouget and Ruben Garcia Alia

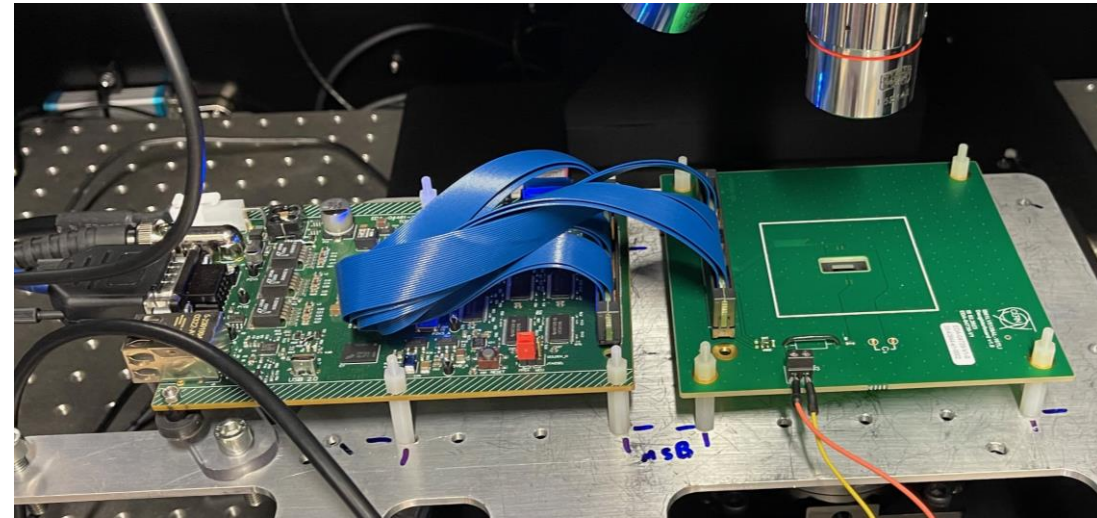
PhD student at IES – Université de Montpellier - CERN

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# Motivation

- Pulsed laser SEE testing has numerous advantages.
- **SRAM memories are interesting devices:**
  - Present in numerous electronic systems,
  - Both discrete and integrated on microcontrollers,
  - Existent for many technology nodes,
  - Used also as radiation monitors, such as RadMon CERN.
- **Large devices (die tens of mm<sup>2</sup> die), allowing extrapolation from some representative areas.**
- **Well characterised set of devices across facilities,**
- **Useful to cross to hadron SEE studies.**
- **Poster presentation at RADECS 2024.**

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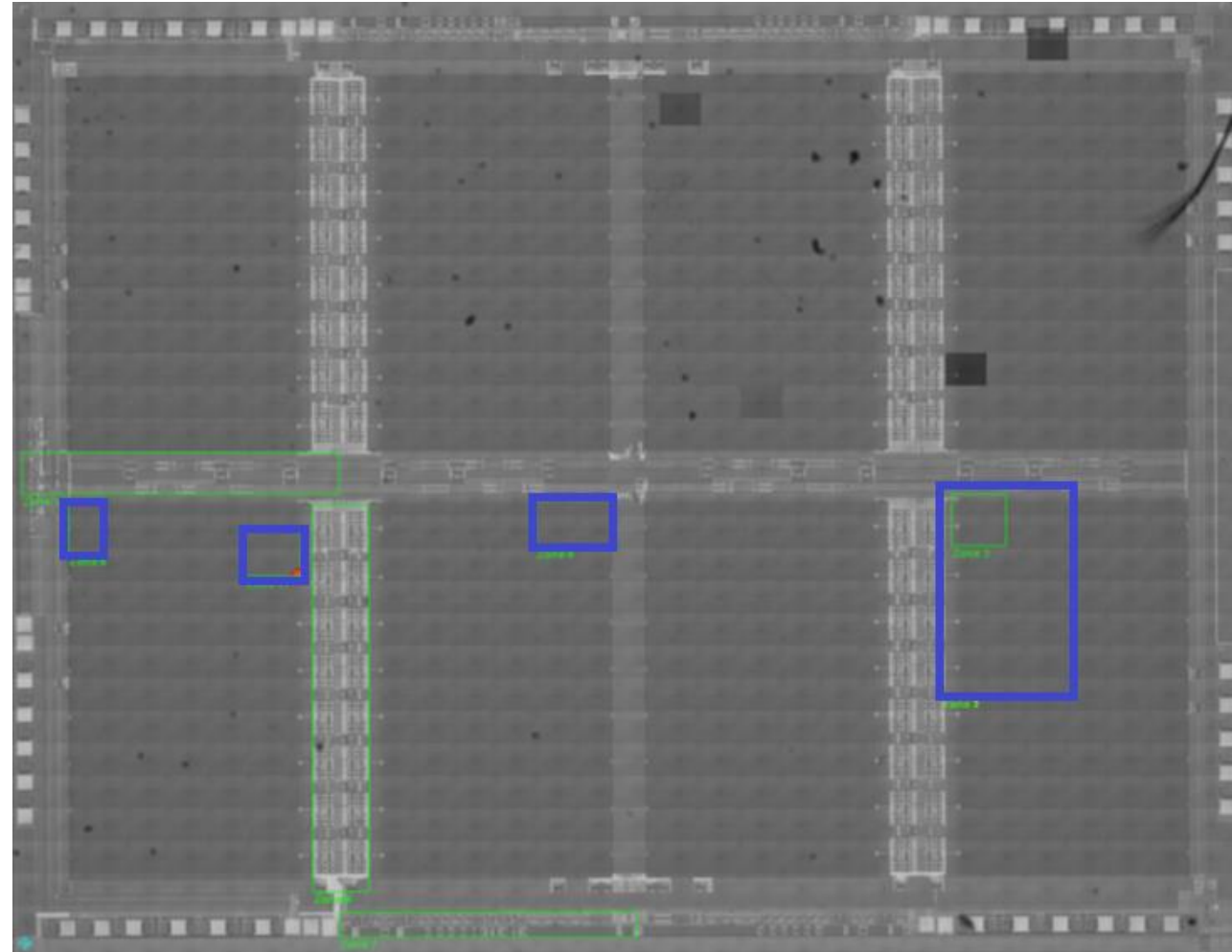


# Memories under test

Reference	Manufacturer	Size [Mbit]	Technology [nm]	SEE study	Threshold [MeV·cm <sup>2</sup> /mg]
CY7C1069AV33-10ZXC	Cypress	16	150	SEL	3.0
IS61LV5128AL-10TLI	ISSI	4	180	SEL	1.6
K6R4016V1D-TC10	Samsung	4	180	SEL	8.6
AS7C34098A-10TCN	Alliance	4	200	SEL	9.2
IS61WV204816BLL-10TLI	ISSI	32	40	SEU	0.2
CY62167GE30-45ZXI	Cypress	16	65	SEU	0.3
RMLV0816BGSA-4S2	Renesas	8	110	SEU	12.0

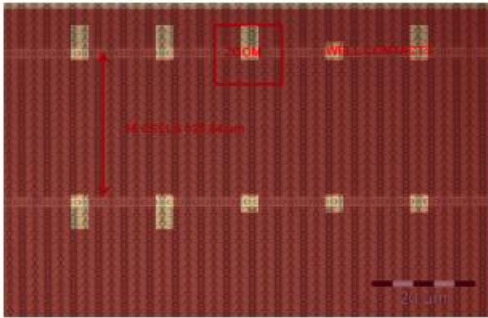
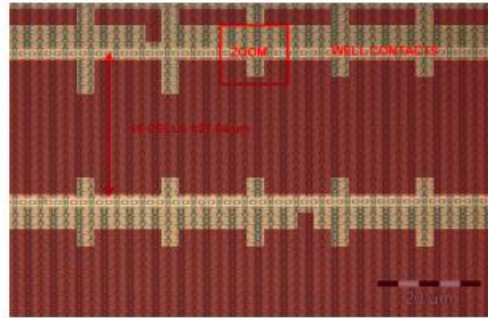
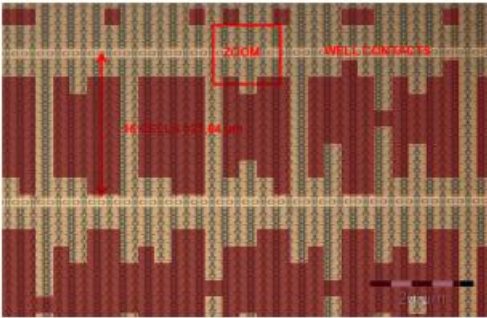
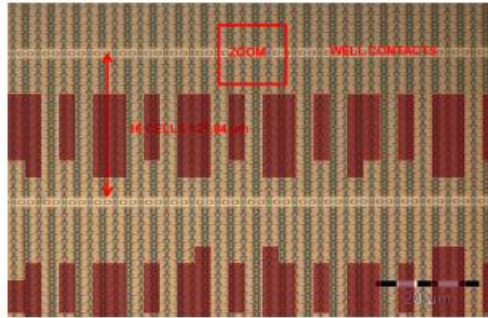
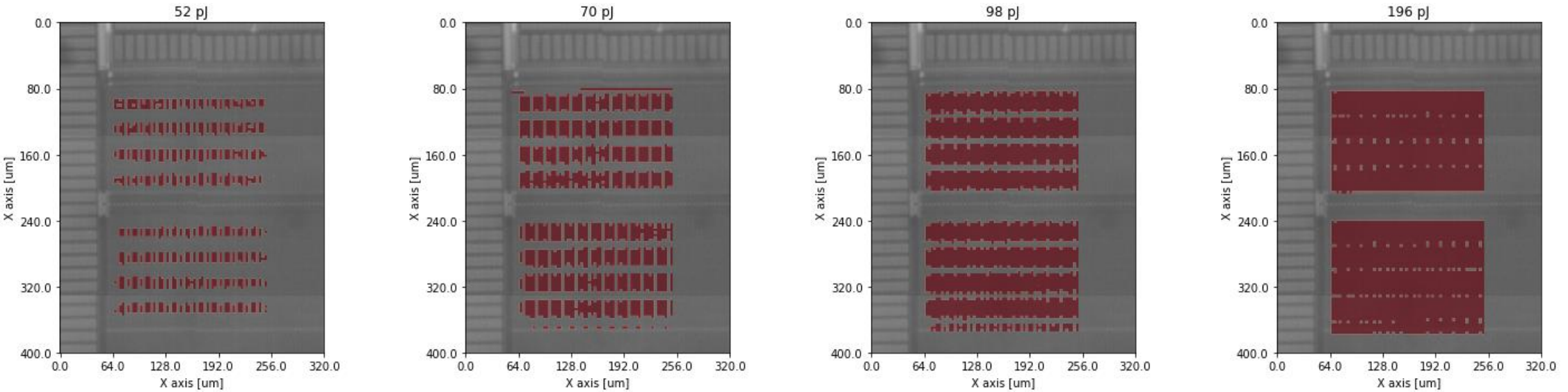
# Test conditions

Setup	IES Preserve - Montpellier
SEE mechanism	SPA
Wavelength	1064 nm
Pulse energy	20 – 600 pJ
Pulse duration	30 ps
Pulse size	~ 1.2 $\mu\text{m}$ (100X)
XY step size	2-20 $\mu\text{m}$
Injection mode	Backside, no thinning



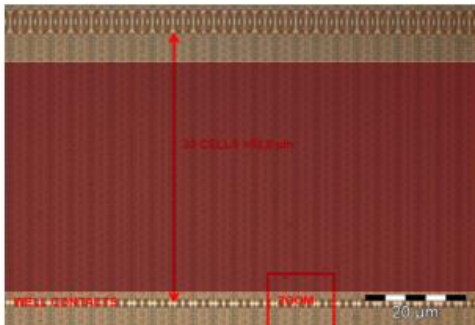
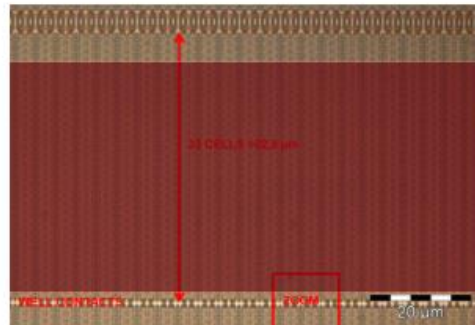
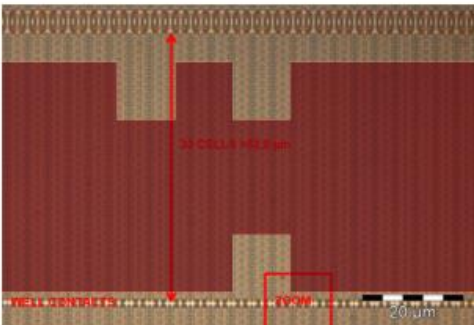
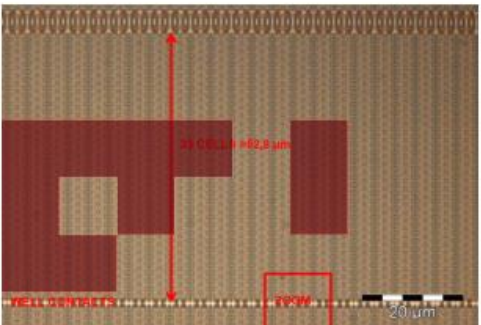
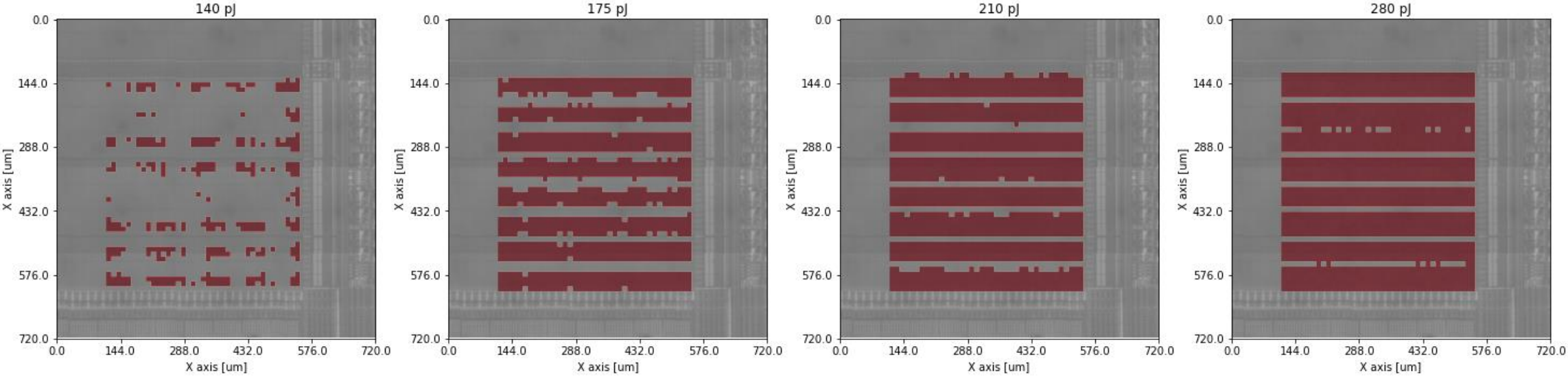
# Mapping IS61LV5128AL

SEL sensitive areas - 3 um step - IS61LV5128AL



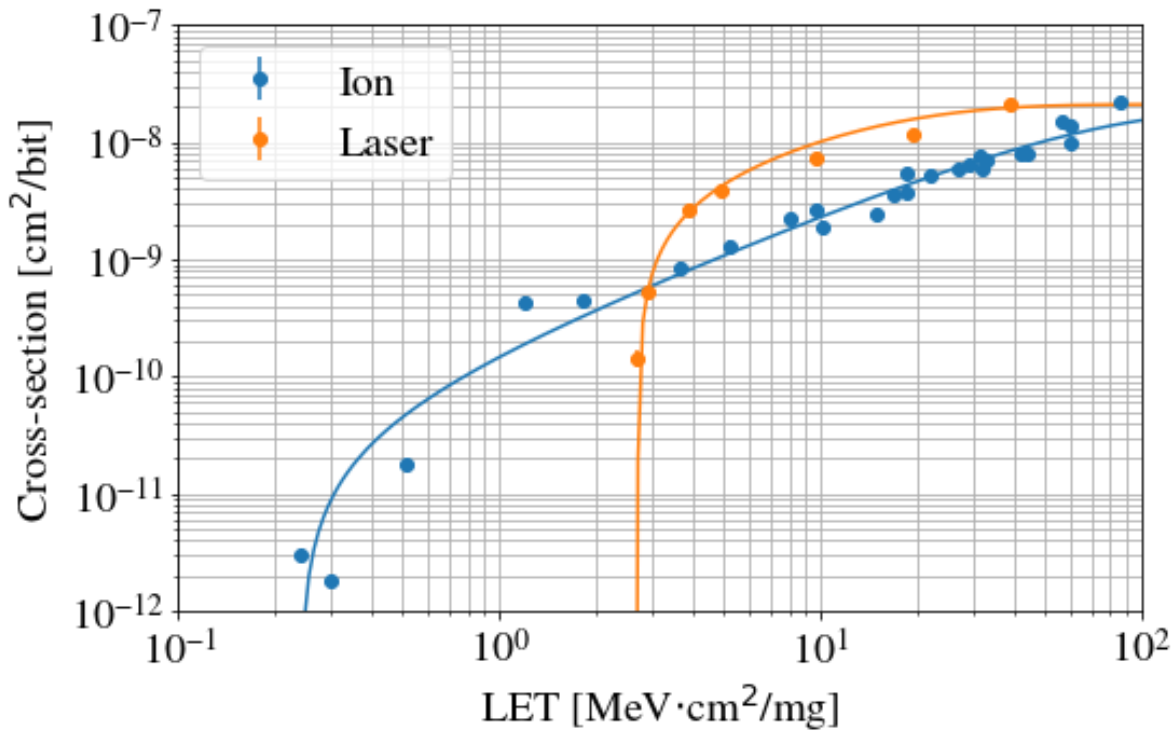
# Mapping K6R4016V1D

SEL sensitive areas - 10 um step - K6R4016V1D

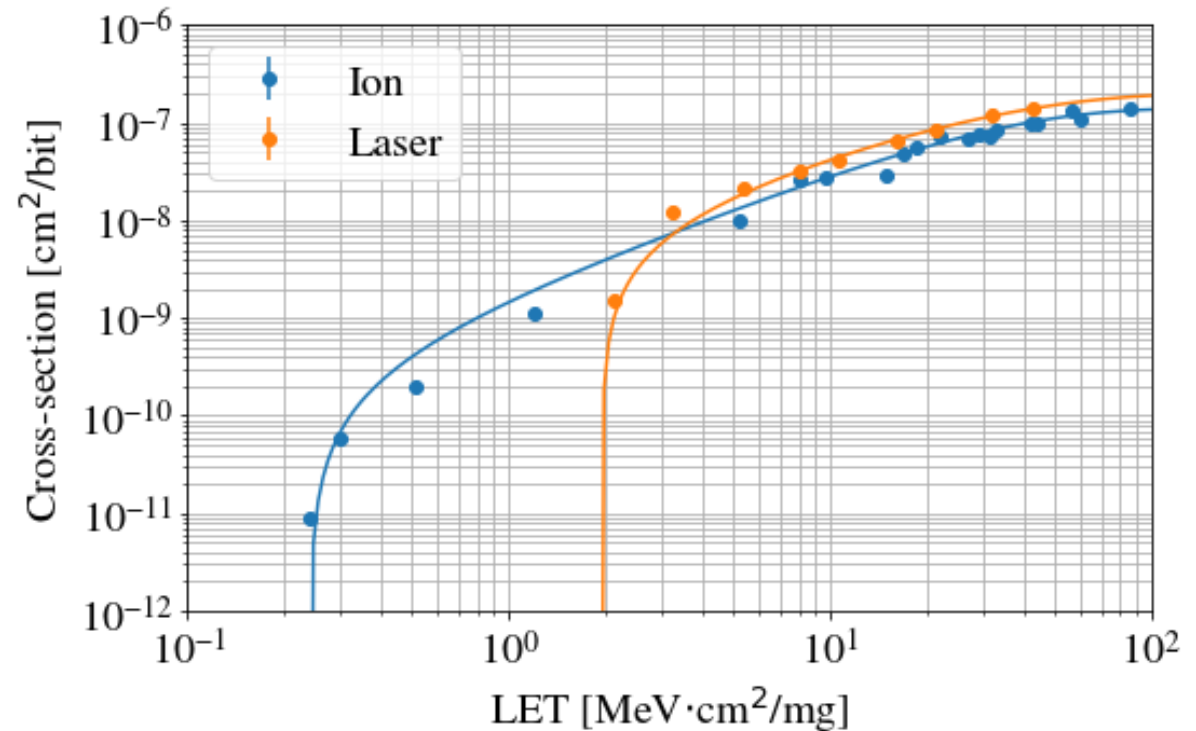


# Deep sub-micron SEU SRAMs

ISSI IS61WV204816BLL

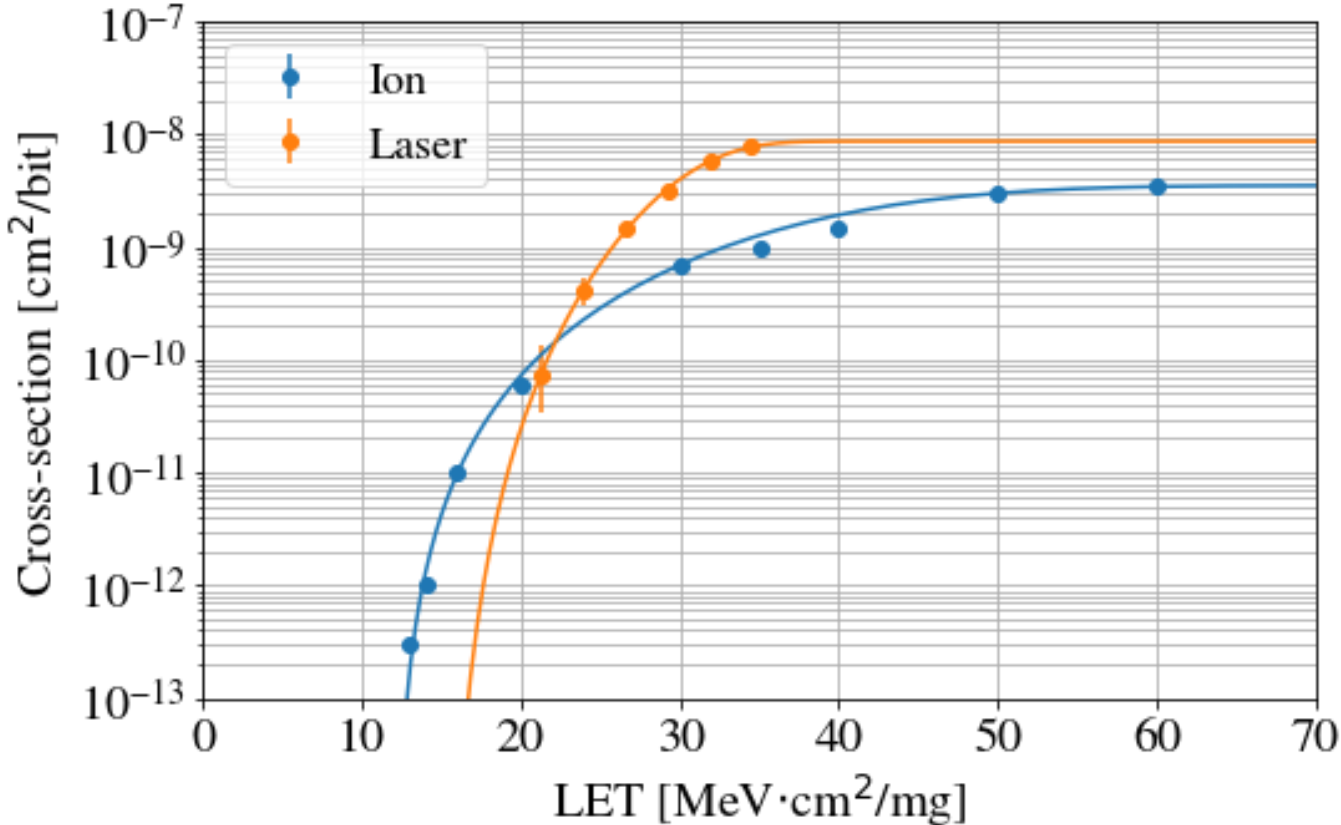


Cypress CY62167GE30



# 110nm SEU SRAM

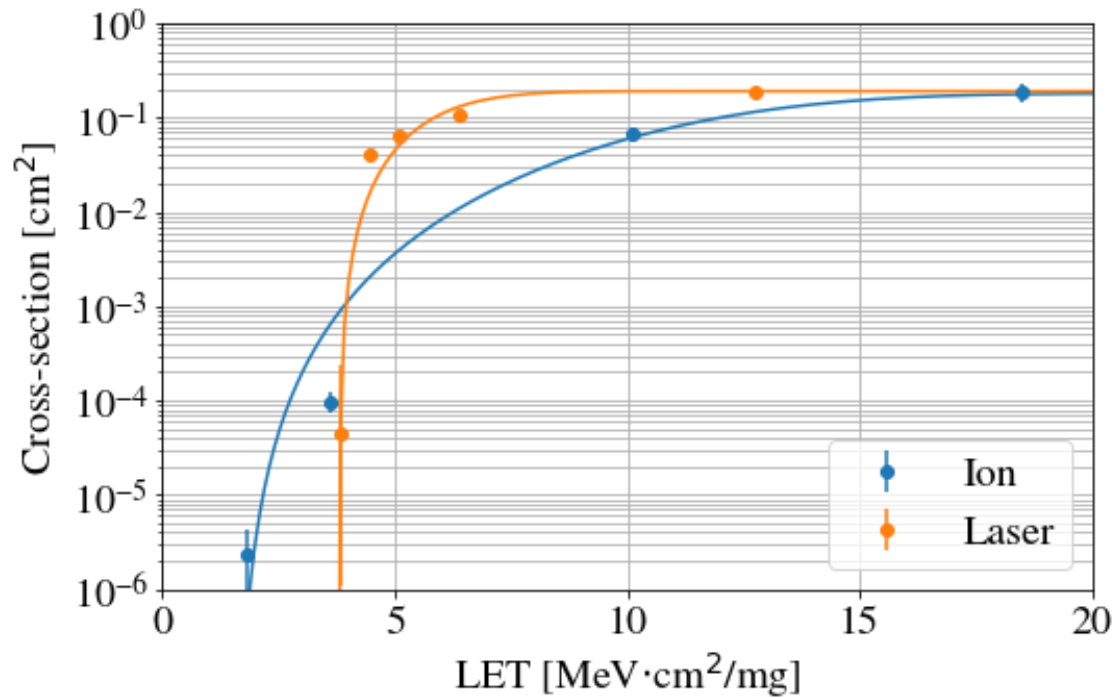
Renesas RMLV0816BGSA



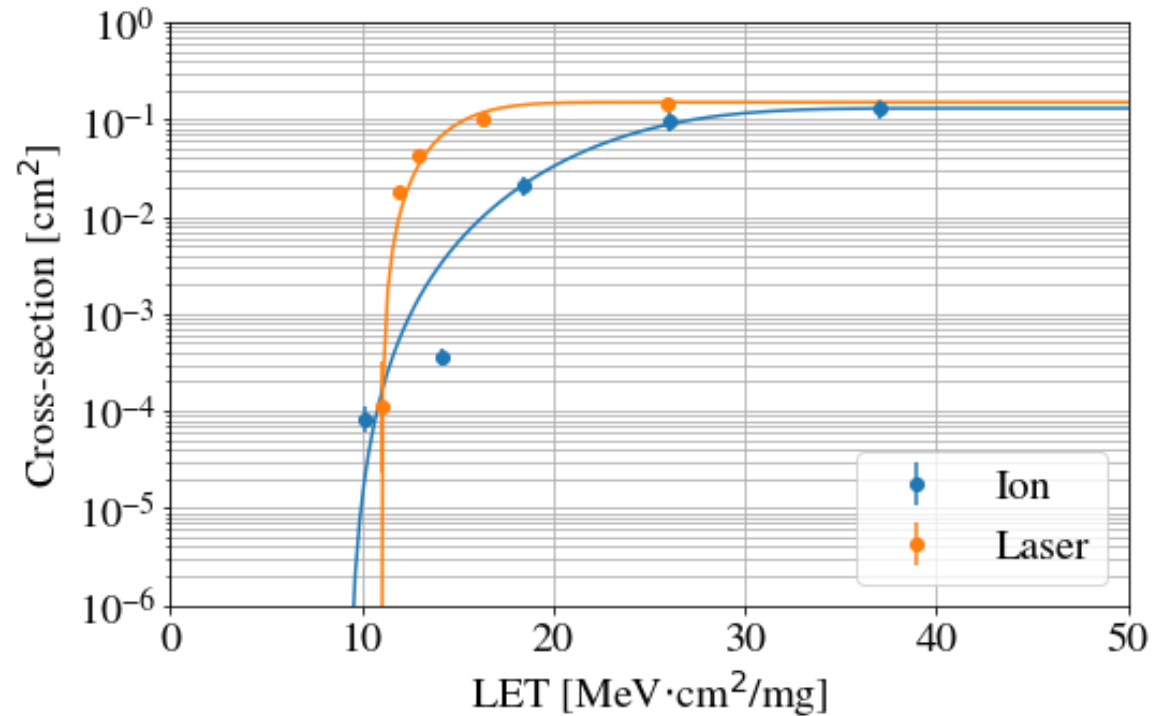


# SEL-sensitive SRAM

ISSI IS61LV5128AL

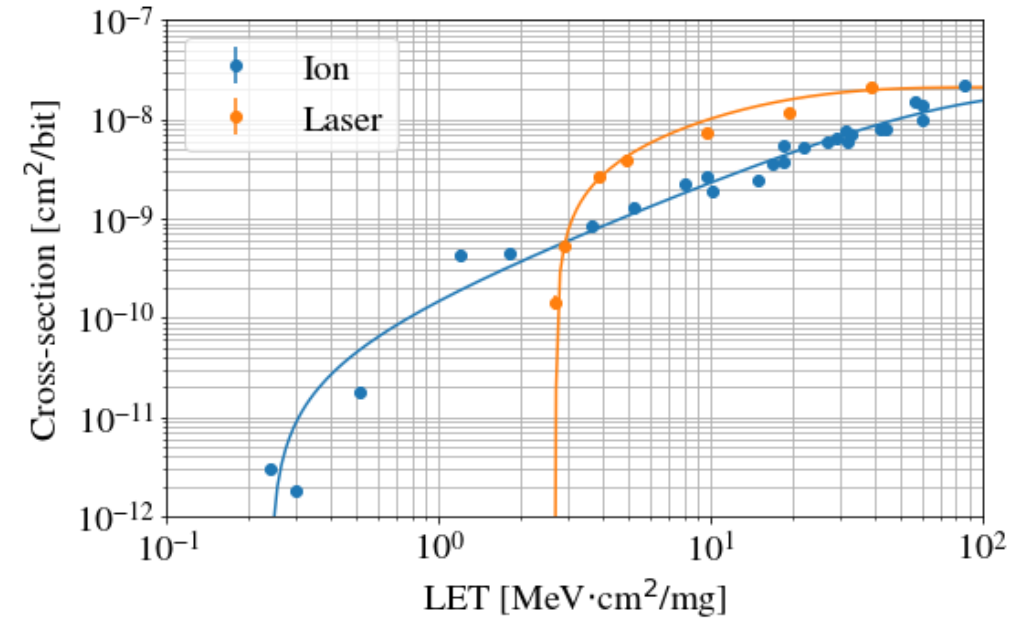


Alliance AS7C34098A



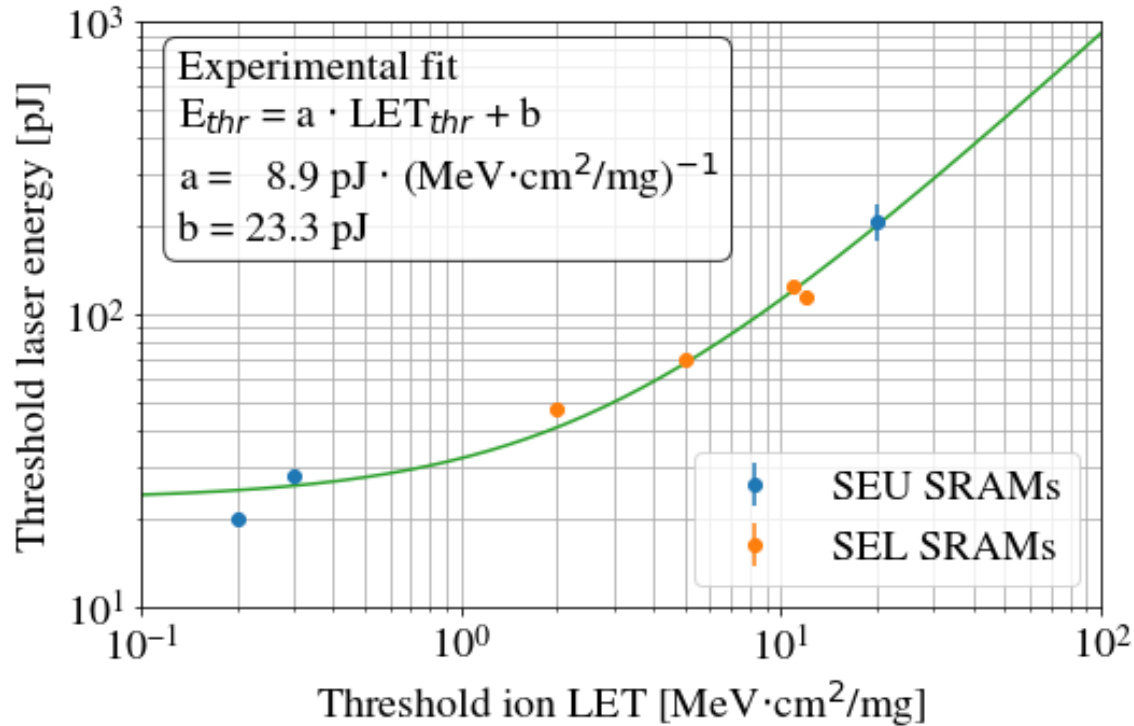
# Weibull parameters head-to-head

- **Higher laser-equivalent LET threshold:** dependant on LET definition.
- **Similar saturation cross-section** (within 10%): Device feature.
- **Lower shape and width parameters:** Fast increase in the cross-section with energy, possibly related to laser pulse shape with energy.

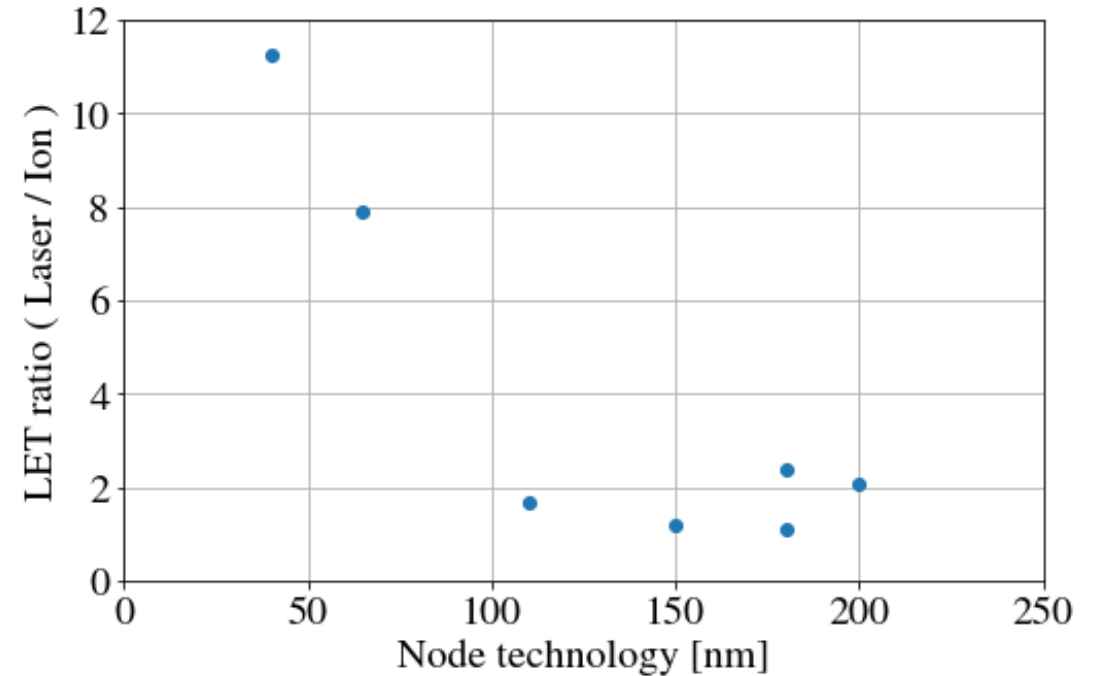


Parameter	Laser compared to ions
$LET_{Th}$	↑
$\sigma_{Sat}$	≈
$S, W$	↓

# Experimental threshold fit



Linear correlation between threshold pulse energy and ion LET (mind the log axes)



Infinite integration laser LET / Ion LET

# Summary

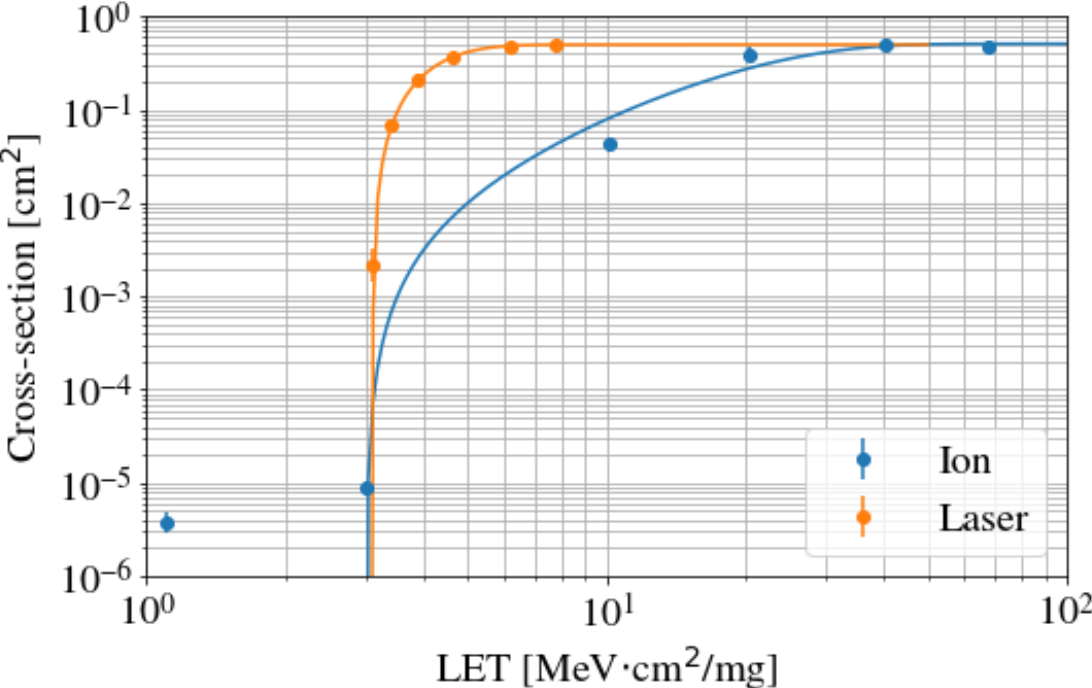


- A set of **seven SRAM memories** (SEL and SEU-sensitive) were tested.
- **Laser** results **compared to standard heavy-ion** SEE tests.
- Confirmed role of contact wells to determine SEL sensitive areas.
- **Weibull fit parameters** were confronted.
- **Linear trend** of laser **threshold energy** with respect to **ion LET** threshold.
- Infinite volume laser-equivalent LET vs ion LET **thresholds deviate for deep submicron SRAMs**, and match for  $> 100$  nm technologies, particularly for threshold  $> 10$  MeV·cm<sup>2</sup>/mg.
- Continuation of the work at RADECS 2024 with SEE rate in-orbit simulations.



# Extra: SEL-sensitive SRAM

Cypress CY7C1069AV33



Samsung K6R4016V1D

